


Refrigerator Contents - ASRC Owned

Chemical Name	Hazardous Components	 NFPA 704 Classification				Additional Training Requirement	Designated Process Hood
		H	F	R	S		
		3-Methacyloxypropyltrimethoxysilane	3-Methacyloxypropyltrimethoxysilane, 3-Trimethoxysilylpropyl 2-methylprop-2-enoate	1	2		
495 PMMA A2	Poly(methylmethacrylate), Anisole	1	2	0	-	NO	Resists Hood, E-beam Spinner
495 PMMA A4	Poly(methylmethacrylate), Anisole	1	2	0	-	NO	Resists Hood, E-beam Spinner
495 PMMA A6	Poly(methylmethacrylate), Anisole	1	2	0	-	NO	Resists Hood, E-beam Spinner
950 PMMA A2	Poly(methylmethacrylate), Anisole	1	2	0	-	NO	Resists Hood, E-beam Spinner
950 PMMA A4	Poly(methylmethacrylate), Anisole	1	2	0	-	NO	Resists Hood, E-beam Spinner
AZ 1512 Photoresist 917 MIF & IN	1-Methoxy-2-propanol acetate, Diazonaphthoquinonesulfonic esters, 2-Methoxy-1-propanol acetate	2	2	0	-	NO	Resists Hood, Photo Spinner
AZ 5214-E Photoresist	1-Methoxy-2-propanol acetate, Diazonaphthoquinonesulfonic esters, 2-Methoxy-1-propanol acetate	2	2	0	-	NO	Resists Hood, Photo Spinner
AZ MiR 701 Photoresist	Ethyl lactate, n-Butyl acetate	2	3	0	-	NO	Resists Hood, Photo Spinner
AZ P4620 Photoresist	1-Methoxy-2-propanol acetate, Diazonaphthoquinonesulfonic esters, 2-Methoxy-1-propanol acetate	2	2	0	-	NO	Resists Hood, Photo Spinner
Immersol 518F	Adipic acid-di(8-methyl-tricyclo (5.2.1.0.2.6) decane) ester, Benzyl benzoate	1	2	0	-	YES	Development Hood
IP-Dip Photoresist	Pentaerythritol triacrylate, o-Phenylphenyl oxyethyl acrylate, 9,9-Bis[4-(2-acryloyloxyethoxy) phenyl]fluorene	2	1	0	-	YES	Development Hood
IP-L 780 Photoresist	Pentaerythritol triacrylate, 7-Diethylamino-3-Thenoylcoumarin	2	1	0	-	YES	Development Hood
IP-S	4,4'-bis-(diethylamino)-benzophenon, 4-hydroxybutyric acid lactone	2	1	0	-	YES	Development Hood
LOR 3A	Cyclopentanone, 1-methoxy-2-propanol	2	3	0	-	NO	Resists Hood, Photo Spinner
ma-N 2403 Negative Photoresist	Cyclopentanone, Anisole	2	1	0	-	NO	Resists Hood, E-beam Spinner
ma-N 2410 Negative Photoresist	Cyclopentanone, Anisole	2	1	0	-	NO	Resists Hood, E-beam Spinner
MIBK:IPA	Methyl isobutyl ketone, Isopropyl alcohol	2	3	1	-	NO	Development Hood
MMA (8.5) MAA EL 12	Poly(methylmethacrylate), Ethyl lactate	2	2	0	-	NO	Resists Hood, E-beam Spinner

S1813 Positive Photoresist	Propylene glycol monomethyl ether acetate, cresol novolak resin, fluoroaliphatic polymer esters, diazo photoactive compound, cresol	2	2	0	-	NO	Resists Hood, Photo Spinner
SPR 220-3.0 Positive Photoresist	Ethyl lactate, Anisole, Diazo photoactive compound, Cresol novolak resin, Cresol, 2-methyl butyl acetate, N-amyl acetate, Organic siloxane surfactant	2	2	0	-	NO	Resists Hood, Photo Spinner
SPR 220-7.0 Positive Photoresist	Ethyl lactate, Anisole, Diazo photoactive compound, Cresol novolak resin, Cresol, 2-methyl butyl acetate, N-amyl acetate, Organic siloxane surfactant	2	2	0	-	NO	Resists Hood, Photo Spinner
SU-8 2 Photoresist	Gamma butyrolactone, Mixed triarylsulfonium/Hexafluoroantimonate salt, Propylene carbonate, Epoxy resin	2	3	0	-	NO	Resists Hood, Others Spinner
SU-8 5 Photoresist	Gamma butyrolactone, Mixed triarylsulfonium/Hexafluoroantimonate salt, Propylene carbonate, Epoxy resin	2	3	0	-	NO	Resists Hood, Others Spinner
SU-8 50 Photoresist	Gamma butyrolactone, Mixed triarylsulfonium/Hexafluoroantimonate salt, Propylene carbonate, Epoxy resin	2	3	0	-	NO	Resists Hood, Others Spinner
SU-8 2000.5 Photoresist	Formaldehyde, Cyclopentanone, Propylene carbonate, Sulfonium	2	3	0	-	NO	Resists Hood, Others Spinner
SU-8 2015 Photoresist	Formaldehyde, Cyclopentanone, Propylene carbonate, Sulfonium	2	3	0	-	NO	Resists Hood, Others Spinner
SU-8 2025 Photoresist	Formaldehyde, Cyclopentanone, Propylene carbonate, Sulfonium	2	3	0	-	NO	Resists Hood, Others Spinner
SU-8 2050 Photoresist	Formaldehyde, Cyclopentanone, Propylene carbonate, Sulfonium	2	3	0	-	NO	Resists Hood, Others Spinner
SU-8 2075 Photoresist	Formaldehyde, Cyclopentanone, Propylene carbonate, Sulfonium	2	3	0	-	NO	Resists Hood, Others Spinner
SU-8 2100 Photoresist	Formaldehyde, Cyclopentanone, Propylene carbonate, Sulfonium	2	3	0	-	NO	Resists Hood, Others Spinner
SU-8 2150 Photoresist	Formaldehyde, Cyclopentanone, Propylene carbonate, Sulfonium	2	3	0	-	NO	Resists Hood, Others Spinner
ZEP 520A	Anisole, Methyl styrene/chloromethyl acrylate copolymer	1	2	0	-	NO	Resists Hood, E-beam Spinner